

# Powerful, Flexible, Single Quadrupole ICP-MS

Agilent 7900 ICP-MS



# The Agilent 7900 ICP-MS Opens Up a New Dimension in Single Quadrupole ICP-MS

Can one ICP-MS combine high performance with great flexibility and ease of use? The answer is yes.

The 7900 ICP-MS has exceptional matrix tolerance, high sensitivity, wide dynamic range, and unmatched helium collision cell mode for control of polyatomic interferences. This high performance is combined with a suite of autotuning, method setup, and data analysis tools that make ICP-MS easier than ever to operate.

Innovative technology and a new MassHunter software platform combine to make the Agilent 7900 the world's most powerful, and most automated quadrupole ICP-MS.

Matrix tolerance has been extended into the tens of %TDS range and the 7900 has a linear dynamic range of 11 orders of magnitude. Plus, the updated octopole reaction system (ORS) supports the industry's most effective helium collision mode.

The Agilent 7900 ICP-MS delivers superior data quality whatever your application.



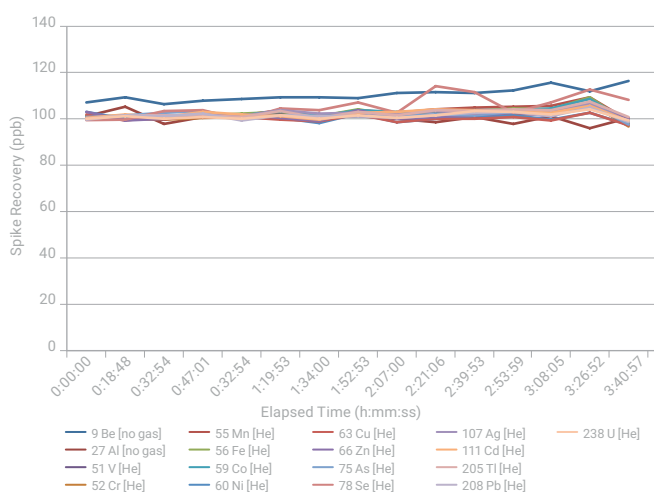
With automated setup, faster analysis, better interference removal, and a simplified MassHunter software interface, the Agilent 7900 ICP-MS blends high performance with unprecedented ease-of-use.

# Unrivalled Performance Driven by Hardware Innovation

## Exceptional matrix tolerance

Historically, ICP-MS has been limited to samples that contain <0.2% total dissolved solids (TDS). The robust plasma (indicated by a CeO/Ce ratio <1%) enables the 7900 ICP-MS to easily tolerate this matrix level.

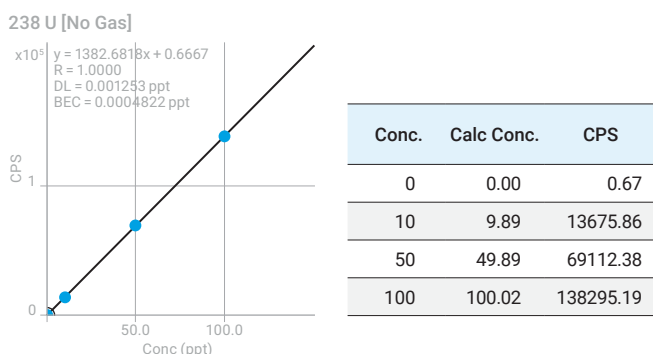
The standard Ultra High Matrix Introduction (UHMI) capability enables you to routinely measure samples containing up to 25% TDS. This is 100 times higher than the traditional limit for ICP-MS, allowing a range of new applications to be addressed.



Long-term (3.5 hours) stability of 100 µg/L spike in 25% NaCl brine

## Better trace-level detection

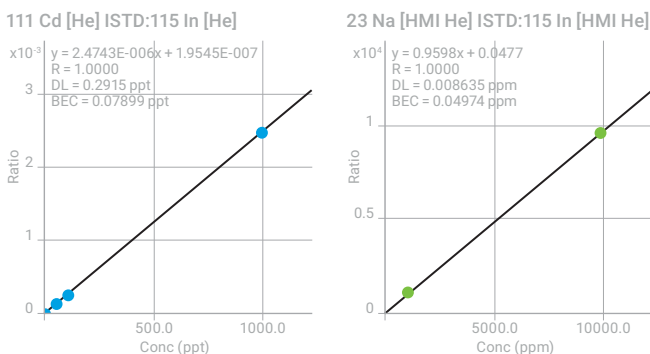
A novel interface design and ion lens and optimized vacuum system increase ion transmission, providing >10<sup>9</sup> cps/ppm sensitivity at <2% CeO. What's more, the new orthogonal detector reduces background, dramatically improving signal-to-noise for lower detection limits and more accurate ultratrace measurements.



<sup>238</sup>U calibration demonstrating sensitivity >1.38 GHz/ppm and BEC < 0.5 ppq

## The widest analytical range of any quadrupole ICP-MS

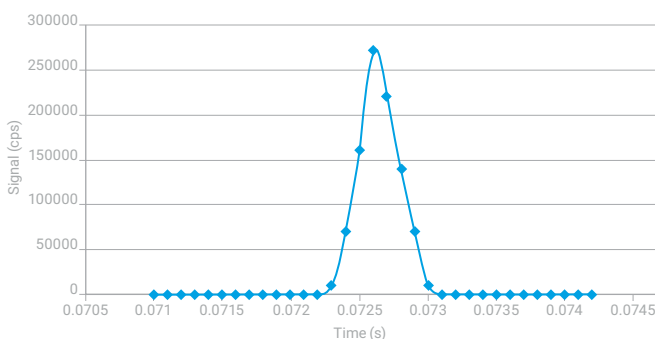
The new Orthogonal Detector System (ODS) delivers up to 11 orders of magnitude dynamic range, from sub-ppt to percent-level concentrations. That means you can measure trace elements and majors in the same run, simplifying method development and virtually eliminating over-range results.



Calibrations for Cd (BEC < 0.1 ppt) and Na (top standard 10,000 ppm (1%))

## Faster analysis of transient signals

Fast transient signal measurement—used for applications such as capillary chromatography, single-nanoparticle and single-cell analysis, and laser ablation—requires an instrument with very short integration times. The 7900 ICP-MS provides ultrafast data acquisition, with 10,000 separate measurements per second.



Time Resolved Analysis signal for single 30 nm Au nanoparticle (dwell time 0.1 ms)

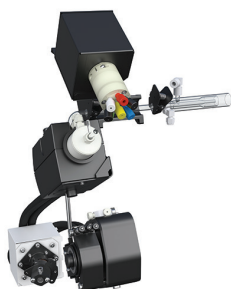
# Usability By Design

## Every component of the Agilent 7900 ICP-MS is engineered for performance and reliability

Based on Agilent's history of ICP-MS technological leadership, the 7900 ICP-MS has been re-engineered from the bench up, with every component optimized for the demands of busy laboratories.

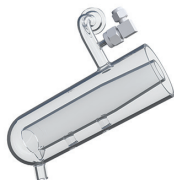
### Sample introduction

The standard low-flow, Peltier-cooled sample introduction system increases operational stability and consistency. The Advanced Valve System (AVS MS) adds a piston pump and close-coupled seven-port valve for high-speed discrete sampling.



### Ultra High Matrix Introduction (UHMI)

Increases matrix tolerance up to 25% total dissolved solids (TDS). UHMI also improves plasma robustness, dramatically reducing matrix suppression.

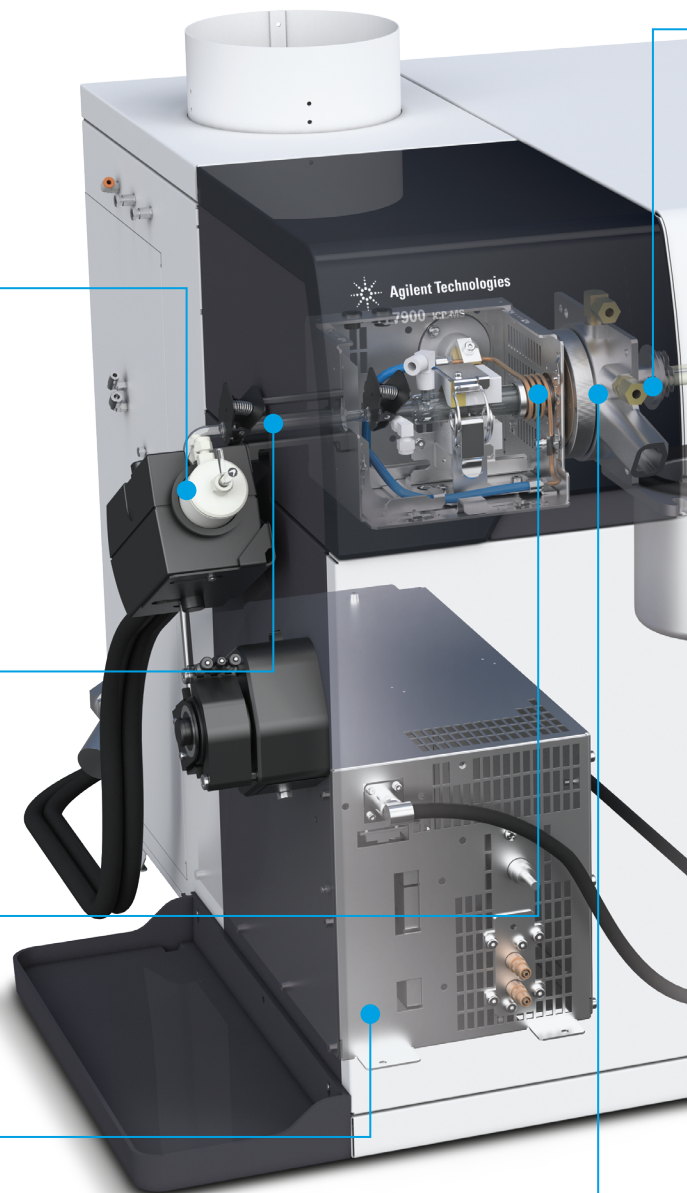


### Plasma and Shield Torch System (STS)

Provides precise ion energy control, ensuring high sensitivity and effective interference removal in helium mode. The torch auto-aligns with the interface following maintenance.

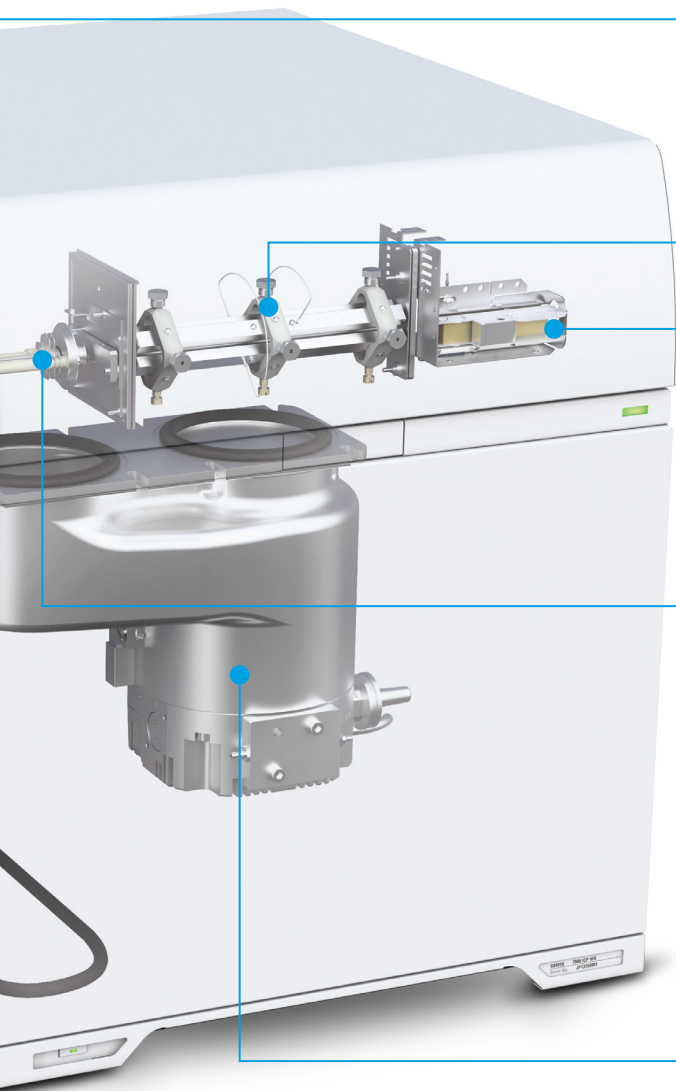
### 27 MHz plasma RF generator

The fast, frequency-matching RF generator increases the tolerance of changing matrices. Even volatile organic solvents can be introduced without affecting plasma stability.



### Interface and cones

Standard Ni, or optional Pt-tipped cones increase ion transmission and matrix tolerance. Screw-threaded for easy removal during maintenance.



### Off-axis ion lens

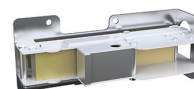
Improves ion transmission across the mass range, minimizing mass bias and eliminating the need for mass-specific voltage optimization.

### Hyperbolic quadrupole

The only hyperbolic quadrupole used in ICP-MS. It delivers superior peak separation and abundance sensitivity, without the need for custom quadrupole settings to separate adjacent peaks.

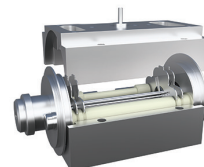
### Orthogonal Detector System (ODS)

The ODS delivers higher sensitivity, lower background, and a wider measurement range—up to 11 orders of magnitude from 0.1 cps to 10 Gcps—virtually eliminating over-range results.



### 4th-Generation Octopole Reaction System (ORS<sup>4</sup>)

Temperature-controlled collision/reaction cell with a new gas controller for fast cell gas switching in less than 3 seconds.



### Octopole ion guide

The octopole provides superior interference removal by KED in helium collision mode, and has been field-proven in thousands of Agilent ICP-MS installations.

### Vacuum system

A single, high-performance split-flow turbo pump and external rotary pump optimize vacuum in the interface region, increasing sensitivity while improving matrix tolerance.

### Compact benchtop design

The world's smallest ICP-MS system saves valuable bench space while ensuring easy access for servicing and maintenance.

### Agilent parts and supplies

Manufactured to stringent specifications, and rigorously tested to ensure top quality and maximize instrument performance.





**Selected Table: Integration Parameters**

Da Internet Net

**Reference** **Reference** **Non-Reference** **Non-Reference** **Concentration**  
 Windows Windows Windows Windows Windows [mM] **Peaks List** Update Parameters Time Update Qualifier for Data

87 200.000 % 2

**General** **Change Global Parameters** **Reset All Peaks to Global** **Reset to Default**

**Integration** ☐ General Integration

**Peak Threshold** ☐ Peak Area [mM]  ☐ Baseline ☐ Baseline

☐ Peak Height [mM]  ☐ Baseline ☐ Baseline

☐ Peak Area [mM]  ☐ Baseline ☐ Baseline

☐ Peak Height [mM]  ☐ Baseline ☐ Baseline

**Minimum number of Peaks**  **pixels**

☐ Exclude the baseline

**Integration Results**

Peak	Area	Height	Baseline
1	100.000	100.000	100.000
2	100.000	100.000	100.000
3	100.000	100.000	100.000
4	100.000	100.000	100.000
5	100.000	100.000	100.000

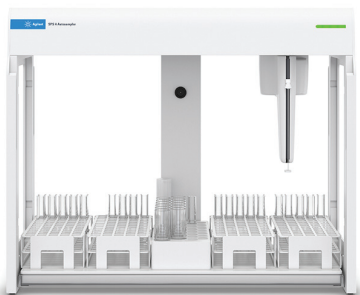
H																	He	<b>Cr</b> Rating 50 52 ★★★★★ 53 ★★★★★ 54				
Li																	Ne					
Na	Mg															Al	Si		P	S	Cl	Ar
K	Ca	Sc	Ti	V	Cr	Mn	Fe	Co	Ni	Cu	Zn	Ga	Ge	As	Se	Br	Kr					
Rb	Sr	Y	Zr	Nb	Mo	Tc	Ru	Rh	Pd	Ag	Cd	In	Sn	Sb	Te	I	Xe					
Cs	Ba	La	Hf	Ta	W	Re	Os	Ir	Pt	Au	Hg	Tl	Pb	Bi	Po	At	Rn					
Fr	Ra																					
		A	La	Ce	Pr	Nd	Pm	Sm	Eu	Gd	Tb	Dy	Ho	Er	Tm	Yb	Lu					
		Ac	Th	Pa	U	Np	Pu	Am	Cm	Bk	Cf	Es	Fm	Md	No	Lr						

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# Enhance the Capability of the 7900 ICP-MS

## Automated sampling systems to optimize your laboratory's workflow



### SPS 4 Autosampler

This flexible-configuration automatic sampler holds up to 360 samples. It is robust, easy to use, and ideal for unattended elemental analysis. Also compatible with well-plates.



### Agilent I-AS Autosampler with pumped rinse station

Ideal for ultratrace analysis and small sample volumes (0.5 mL). Flexible rack configurations offer a maximum capacity of 89 vials, plus 3 rinse vials. Combined with the 7900s (option #200), the I-AS is ideal for ultratrace analysis of high purity semiconductor reagents.



### Advanced Valve System (AVS MS)

High-speed uptake pump and close-coupled seven-port switching valve provide highest possible throughput with discrete sampling.

### Industry-leading speciation measurement

The Agilent 7900 ICP-MS can be combined with Agilent HPLC systems through a field-proven interface, documentation, and fully developed application kits. Other hyphenated techniques including CE, IC, and FFF are also easily configured.

Factory-qualified engineers are also available to support your coupled systems.



### Advanced Dilution System (ADS)

Designed and manufactured by Agilent, the ADS automates standard preparation and pre-run sample dilutions. It also automates post-run sample dilutions for over-range samples using real-time reactive dilutions during the analysis. Automating dilutions removes common sources of human error, contamination, and wasted time.



### Optional accessories support a range of configurations and applications

**Nebulizer options**—including low-flow, concentric, inert (HF resistant), and parallel path—suit your unique sample types and volumes.

**Inert sample introduction kit** is O-ring free, and manufactured from PFA for low contamination levels. HF resistant and suitable for high-purity reagents.

**Organics kit** contains the sample introduction parts you need to run volatile organic solvents.

**Laser ablation** enables direct sample analysis for bulk and time-resolved applications.

### Software control

Virtually unlimited possibilities for optional accessories are now available via Agilent's open-source Software Developers Kit (SDK).

## Agilent CrossLab: Real insight, real outcomes

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DE.2176041667

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Published in the USA, October 28, 2025  
5991-3719EN

